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## On the metal-insulator transition in n-type doped CuGaSe<sub>2</sub>

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**Abstract.** Transport properties of n-type CuGaSe<sub>2</sub> single crystals are investigated in the temperature range from 2 to 350 K. The effective donor concentration is varied between  $2 \times 10^{12}$  and  $4.4 \times 10^{17}$  cm<sup>-3</sup> by co-doping with Ge and Zn. The charge transport properties are analysed and interpreted in the framework of an Anderson metal-insulator transition. A critical donor concentration  $N_c$  of  $1.4 \times 10^{17}$  cm<sup>-3</sup> is estimated, which is in good agreement with the Mott criterion  $(N_c^{1/3} \approx 0.25/a_H)$ . However, the second characteristic concentration, above which the Fermi level merges into the conduction band, was not observed experimentally. This is in accordance with an estimate of  $7 \times 10^{17}$  cm<sup>-3</sup> according to the Matsubara–Toyozawa criterion, which exceeds the highest donor concentrations achieved in this material so far. The effective dopant density in n-type CuGaSe<sub>2</sub> is limited by self-compensation due to intrinsic defects (mainly Cu vacancies). Furthermore, at low temperatures a crossover from Mott- to Efros–Shklovskii-type variable range hopping is observed on the dielectric side of the transition.

#### 1. Introduction

CuGaSe<sub>2</sub> (CGS), belonging to the I–III–VI<sub>2</sub> family of chalcopyrite compounds, has been studied as a promising material for photovoltaic applications. Because its energy gap of 1.72 eV is well suited for the solar spectrum, efficiencies exceeding 9% have been obtained for single crystal as well as thin film solar cells [1, 2]. Recently, it has been demonstrated that n-type CGS can be achieved by co-doping with Ge and Zn [3]. The samples have been doped with Ge by ion implantation and post-treated in a Zn atmosphere. Room temperature carrier concentrations of  $10^{16}$  cm<sup>-3</sup> have been reported. Here we show that the carrier concentration at room temperature can be increased significantly by optimizing the post-deposition annealing parameters. Electron densities at room temperature as high as  $4.4 \times 10^{17}$  cm<sup>-3</sup> are achieved. It was previously shown that at high donor concentrations an impurity band is formed [4]. In this study we investigated the electronic transport properties of n-CGS single crystals as a function of the effective, uncompensated donor density  $(N_d - N_a)$ .

At low donor concentrations there is a negligible overlap of the hydrogenic wave functions of the donor levels. Hence, the material is insulating. At high concentrations the material becomes a metal, when the overlap is large compared to the on-site electron–electron repulsion. The transition from the insulating to metallic state (i.e., localized to itinerant electrons) occurs at a critical concentration  $N_c$ , when the average spacing between the impurities is approximately four times the Bohr radius [5]. This kind of metal–insulator transition (MIT) has also been observed in n-CuInSe<sub>2</sub>, a closely related compound [6]. Another view of the MIT, due to Anderson [7], involves localization due to random one-electron potentials seen by the electrons. At low donor densities the energy spread in the random potential of the disordered system is

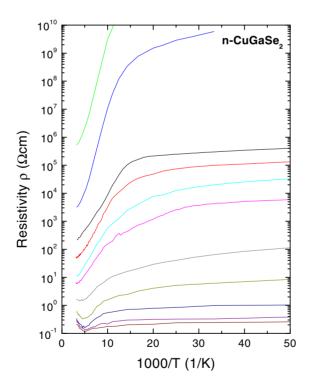
large compared to the energy bandwidth. As a result of this, the electronic states of the system are localized. At higher concentrations extended states, separated by a mobility edge, are formed. Within the Anderson framework the MIT occurs if the Fermi level  $E_F$  is pushed through the mobility edge by the addition of electrons [7, 8]. Mott proposed a discontinuous drop [9] of the zero-temperature electrical conductivity at  $N_c$ , whereas scaling theories of localization suggest a continuous decrease [8, 10] as the donor concentration is lowered to  $N_c$ . The experimental results for n-CGS will be discussed in the framework of an Anderson MIT.

#### 2. Experimental methods

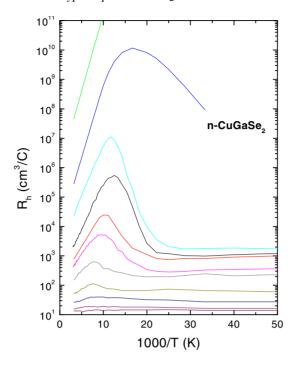
CGS single crystals were grown by chemical vapour transport using iodine as transport agent. Some crystals were doped during CVT growth with Ge and Zn, resulting in highly resistive n-type material. Ge-ion implantation was carried out using an energy of 150 keV and a dose of  $5 \times 10^{15}$  cm<sup>-2</sup> on undoped CGS crystals [3]. Annealing in the presence of Zn was carried out in a flow of hydrogen for 24 h at temperatures up to  $500\,^{\circ}$ C. Resistivity and Hall-effect measurements (magnetic field up to 2 T) were carried out in the temperature range from 2 to 350 K using a conventional DC set-up. Furthermore, magnetoresistance at low temperatures has been studied in these samples using magnetic fields up to 8 T. Ohmic contacts to n-CGS samples were prepared using thermal evaporation of In.

#### 3. Results and discussion

Co-doping with Ge and Zn provides a means to obtain n-type CGS crystals [3]. Resistivity  $\rho$  and Hall coefficient  $R_h$  of the various samples are shown in figures 1 and 2 as functions of



**Figure 1.** Resistivity of doped n-type CuGaSe<sub>2</sub> single crystals as a function of reciprocal temperature (sample 1 (top curve) to sample 11 (bottom curve)).



**Figure 2.** Hall coefficient of doped n-type CuGaSe<sub>2</sub> single crystals as a function of reciprocal temperature (sample 1 (top curve) to sample 11 (bottom curve)).

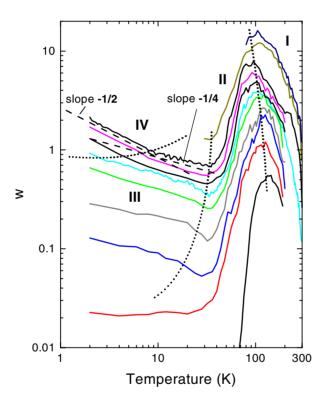
temperature. The electron mobility in these samples is in the range of 100 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup> at room temperature and reaches maximum values up to 500 cm<sup>2</sup> V<sup>-1</sup> s<sup>-1</sup> at low temperatures. The donor and acceptor concentrations  $N_d$  and  $N_a$ , the activation energy  $E_d$  and the degree of compensation  $K = N_a/N_d$  can be estimated from the Hall coefficient  $R_h$  [3,4]. The effective donor concentration  $(N_d - N_a)$  can be estimated in the carrier freezing region and the degree of compensation can be extracted from the temperature dependence of the Fermi energy assuming a one donor and one acceptor model [4]. The obtained values are summarized in table 1. The effective donor concentration  $(N_d - N_a)$  depends significantly on the preparation of the samples. Whereas CVT growth generally results in heavy compensation ( $K \approx 1$ ), additional annealing in the presence of Zn reduces the degree of compensation. We assume that spontaneous formation of Cu vacancies ( $V_{Cu}$ ) causes strong self-compensation as the Fermi level shifts to the conduction band [11–13]. This is minimized in the presence of Zn due to the formation of  $Zn_{Cu}$  defects, which act as additional donors in contrast to compensating  $V_{Cu}$ acceptor levels. At too high Zn-annealing temperatures the degree of compensation increases again (see table 1), which might be ascribed to the formation of  $Zn_{Ga}$  acceptor defects [14]. Furthermore, Ge doping becomes more effective due to an increase of  $Ge_{Ga}$  levels compared to  $Ge_{Cu}$  defects [3]. We believe that  $Ge_{Ga}$  forms a much more shallow level in CGS than  $Ge_{Cu}$ . However, a detailed microscopic understanding of self-compensation and co-doping in CGS is still missing.

In order to analyse the temperature dependence of the resistivity we used the reduced activation energy w, given by [15]

$$w = \frac{E}{kT} = \frac{1}{T} \frac{\mathrm{d} \ln \rho}{\mathrm{d} T^{-1}}.\tag{1}$$

**Table 1.** Summary of the electrical properties (effective donor concentration  $N_d-N_a$ , characteristic Mott hopping temperature  $T_0$ , donor activation energy  $E_d$ , compensation ratio  $K=N_a/N_d$ , localization length  $\xi$ ) of the various n-CuGaSe<sub>2</sub> samples studied. The samples were doped during the chemical vapour transport growth (CVT) or by a subsequent ion-implantation step (Im). The numbers in the second column correspond to the Zn-annealing temperature in  ${}^{\circ}$ C.

C1-	Growth	$N_d - N_a$	$T_0$	$E_d$	V	ξ
Sample	parameters	$(cm^{-3})$	(K)	(meV)	K	(nm)
1	CVT	$2\times10^{12}$		99	0.99996	
2	CVT/350	$3 \times 10^{14}$	35 000	102	0.998	7.4
3	CVT/400	$3.6 \times 10^{15}$	29 000	86	0.95	7.9
4	Im/350	$6.4 \times 10^{15}$	22 000	79	0.89	8.6
5	CVT/500	$7.9 \times 10^{15}$	15 000	74	0.89	9.9
6	Im/375	$1.7 \times 10^{16}$	5 500	68	0.93	13.7
7	CVT/450	$4.4 \times 10^{16}$	580	49	0.54	29.4
8	Im/400	$1.2 \times 10^{17}$	3	23	0.81	165
9	Im/425	$2.2 \times 10^{17}$	_	4	0.64	
10	Im/475	$3.5 \times 10^{17}$	_	_	0.27	
11	Im/450	$4.4\times10^{17}$	_	_	0.41	



**Figure 3.** Reduced activation energy w of doped n-type CuGaSe<sub>2</sub> single crystals as a function of temperature (sample 1 (top curve) to sample 11 (bottom curve)). The different regions (I–IV) are described in the text. The dashed lines correspond to a slope of -1/2 (Efros–Shklovski variable range hopping) and -1/4 (Mott variable range hopping).

By plotting  $\log w$  against  $\log T$  it is possible to identify the different regions of charge transport (see figure 3). Over the whole temperature range we can discern two (I, III)

characteristic regions with different temperature dependences separated by a transition region (II). At low temperatures the transport is governed by tunnelling and hopping. The electrical conductivity occurs by electronic excitations in the vicinity of the Fermi level. The charge transport (except for the two samples with the highest carrier concentration) can be described by Mott-type variable range hopping [16]:

$$\rho(T) = \rho_0 \exp\left(\frac{T_0}{T}\right)^{1/4}.$$
 (2)

In some samples we observe a crossover from Mott-type to Efros–Shklovskii-type variable range hopping (region IV), where the resistivity is given by [17]:

$$\rho(T) = \rho_{ES} \exp\left(\frac{T_{ES}}{T}\right)^{1/2}.$$
(3)

Efros–Shklovskii hopping is expected in the presence of a parabolic 'Coulomb gap'. If the thermal hopping energy becomes large compared to the energy width of the gap a crossover to Mott-type variable range hopping can be observed [18]. A detailed study of the crossover and the 'weakening' of the 'Coulomb gap' due to finite temperature effects will be reported elsewhere [19]. The different hopping regimes can be identified by the different slopes in the plot of  $\log w$  against  $\log T$  (figure 3),  $-\frac{1}{2}$  for Shklovskii–Efros and  $-\frac{1}{4}$  for Mott-type hopping, respectively.

The characteristic hopping temperatures  $T_0$  and  $T_{ES}$  are obtained from a fit of the experimental data to equations (2) and (3), respectively, using a fixed hopping exponent of  $\frac{1}{4}$  and  $\frac{1}{2}$ . The characteristic Mott temperature  $T_0$  allows us to estimate the localization length  $\xi$  by [20]

$$\xi = \left(\frac{18}{kT_0N(E_f)}\right)^{1/3} \tag{4}$$

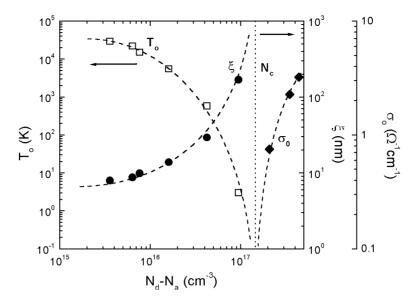
where  $N(E_f)$  is the density of states at the Fermi energy  $E_f$ . However, the exact value of  $N(E_f)$  is not known. A rough estimation can be obtained using [17, 21]

$$N(E_f) \approx \frac{KN_d}{E_0} \tag{5}$$

where  $E_0 = e^2/(4\pi \varepsilon_0 \varepsilon_r r_d)$  is the energy of the Coulomb repulsion and  $r_d = (4\pi N_d/3)^{-1/3}$  is half the mean distance between the donors. Similar values of  $N(E_f)$  are obtained from the positive magnetoresistance at moderate fields. Hence, we assume that the estimation accords to a reasonable approximation of  $N(E_f)$ . Using the estimated value for  $N(E_f)$  and equation (4) the coherence length can be calculated. The values for  $\xi$  are summarized in table 1. Note that  $\xi$  is expected to diverge as the MIT is approached from the insulating side. Hence,  $T_0$  should go to zero at the transition, which is observed experimentally (see figure 4). A critical concentration  $N_c$  of  $1.4 \times 10^{17}$  cm<sup>-3</sup> can be estimated graphically (see figure 4). The value of  $N_c$ , which defines the MIT, is given by the Mott criterion [5]

$$N_c \approx (0.25/a_H)^3 \tag{6}$$

where  $a_H$  is the Bohr radius of the impurity atom ( $a_H = a_0 \varepsilon_r / m^*$ ) and  $a_0$  that of hydrogen. Using values of  $m^* = 0.11 \ m_e$  (obtained from Hall- and Seebeck-effect measurements) [22] and  $\varepsilon_r = 9.6$  [23], a value of  $1.5 \times 10^{17} \ \rm cm^{-3}$  can be estimated. On the metallic side of the transition the activated temperature dependence of the resistivity (samples 1–9) changes to a power law behaviour (samples 10, 11) [5]. Furthermore, the low temperature conductivity  $\sigma_0$  (estimated from the conductivity measured at 2 K) goes to zero for dopant concentrations close



**Figure 4.** Characteristic Mott temperature  $T_0$ , localization length  $\xi$  and low temperature conductivity  $\sigma_0$  as functions of uncompensated, effective donor concentration  $N_d-N_a$ . A critical concentration of  $1.4\times 10^{17}~{\rm cm}^{-3}$  is estimated graphically (vertical line). The dashed lines are a guide to the eye.

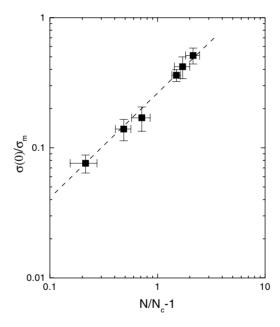
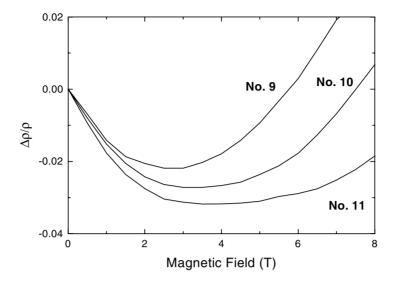


Figure 5. Low temperature conductivity  $\sigma_0$  as a function of donor concentration  $N/N_c-1$   $(N=N_d-N_a)$  for samples on the metallic side of the transition. The dashed line corresponds to a critical exponent of the order of one  $(\sigma(0)/\sigma_m \approx (N/N_c-1))$ .

to  $N_c$  (see figures 4 and 5). The decrease agrees well with a critical exponent  $\nu$  of the order of 1 according to scaling theories [10, 24]

$$\sigma(0)/\sigma_m = ((N_d - N_a)/N_c - 1)^v$$
(7)



**Figure 6.** Magnetoresistance of samples 9–11 at 4 K. The minimum shifts to higher magnetic fields as  $N_d - N_a$  approaches  $N_{CB}$ .

where  $\sigma_m$  is the minimum metallic conductivity ( $\sigma_m = 0.05e^2N_c^{1/3}/\hbar$ ) [9]. It has been pointed out that disorder and compensation broadens the shape of the conductivity– $N/N_c-1$  curves [24]. This might arise due to a decrease of the relative importance of Coulomb interactions [25] compared to the random potential scattering considered by localization theory [26].

A second characteristic concentration,  $N_{CB}$ , above which the Fermi level merges into the conduction band and leads to the metallic conduction, is expressed according to the Matsubara–Toyozawa criterion [27].  $N_{CB}$  can be related to  $N_c$  by approximately  $N_{CB} \approx 5N_c$  [28]. Hence a value of  $7 \times 10^{17}$  cm<sup>-3</sup> can be estimated for  $N_{CB}$ , which is higher than the highest doping concentration achieved so far (sample 11). In the intermediate regime  $(N_c < (N_d - N_a) < N_{CB})$  the charge transport is governed by a conducting 'impurity' band. The magnetoresistance at low temperatures (4 K) exhibits a minimum (see figure 6). This minimum moves to higher magnetic fields with increasing donor concentration. A vanishing of this minimum has been observed in doped Si [28] for concentrations exceeding  $N_{CB}$ . This shows that the carrier concentration in n-CGS approaches  $N_{CB}$ , but is still smaller than  $N_{CB}$ . The positive and negative contributions to the magnetoresistance may arise from orbit shrinkage, Coulomb interaction [29] or localization effects [30]. The magnetoresistance in n-CGS will be the topic of a forthcoming article.

The thermal activation energy of the dominant donor level, which is tentatively ascribed to  $Ge_{Ga}$  defects [3], decreases with increasing effective donor concentration (see figure 7). This can be explained by screening effects. Generally,  $E_d(N_d - N_a)$  might be described by [31]

$$E_d(N_d - N_a) = E_{d0} - \alpha (N_d - N_a)^{1/3}$$
(8)

where  $E_{d0}$  is the thermal ionization energy of the donor level in the infinite dilution limit and  $\alpha$  a constant describing the electrostatic screening. Values of  $E_{d0} \approx 103$  meV and  $\alpha \approx 14 \times 10^{-5}$  meV cm are estimated. However, at high concentrations the donor activation energy drops to zero, indicating the crossover to metallic (non-activated) conductivity. The position of this drop agrees reasonably well with the concentration  $(1.4 \times 10^{17} \, \mathrm{cm}^{-3})$  determined from the hopping transport and  $\sigma(0)$  (see dashed line in figure 7).

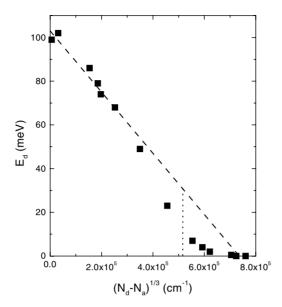


Figure 7. Thermal donor activation energy  $E_d$  as a function of the uncompensated, effective donor concentration  $N_d - N_a$ . The dashed line corresponds to a fit to equation (7) and the dotted line shows the critical donor concentration of the metal–insulator transition  $N_c$ .

Although the estimated value of the critical donor concentration in n-CGS corresponds reasonably well with the Mott criterion, one has to keep in mind that the introduced donor levels are not hydrogen-like. Assuming  $m^* = 0.11 \ m_e$  and  $\varepsilon_r = 9.6$ , an activation energy of 16 meV can be estimated for a hydrogen-like donor in n-CGS. This is much smaller than the value of 103 meV obtained for  $E_{d0}$ . Furthermore, the different samples show a different degree of compensation K ( $K = N_a/N_d$ ). It has been reported that  $N_c$  for a given material also depends on compensation [32, 33]. However, the framework of the Anderson MIT accounts for a good qualitative description of the observed data and therefore, for the doping-induced MIT in compensated n-CGS.

#### 4. Conclusions

The doping-induced Anderson-type metal–insulator transition in n-CuGaSe $_2$  single crystals is studied. A critical donor concentration of  $1.4 \times 10^{17}$  cm $^{-3}$  is estimated, which is in good agreement with the Mott criterion. At low temperatures, variable range hopping is observed on the dielectric side of the transition. Furthermore, a crossover from Mott- to Efros–Shklovskiitype conduction is found. The maximum carrier concentration on the metallic side is limited by self-compensation due to intrinsic defects. A maximum donor concentration of  $4.4 \times 10^{17}$  cm $^{-3}$  is achieved.

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